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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/719,739	11/20/2003	Tomoki Ono	245402008000	3121
25226	7590	04/20/2005	EXAMINER	
MORRISON & FOERSTER LLP			RAO, SHRINIVAS H	
755 PAGE MILL RD			ART UNIT	
PALO ALTO, CA 94304-1018			PAPER NUMBER	
			2814	

DATE MAILED: 04/20/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

H.A

**Office Action Summary**

Application No.

10/719,739

Applicant(s)

ONO ET AL.

Examiner

Steven H. Rao

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 03 February 2005.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-18 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☐ Claim(s) 1-18 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)  | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)                                   | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)             |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)<br>Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____  |

***Response to Amendment***

Applicants' amendment filed on February 03, 2005 has been entered and forwarded to the Examiner on February 03, 2005.

Therefore claims 1-16 as amended by the amendment and claims 17-18 as previously recited are currently pending in the application.

***Drawings***

New corrected drawings in compliance with 37 CFR 1.121(d) are required in this application because the presently added limitation in claims "an optical cavity" is not shown in the figures.

Appropriate correction is required.

Applicant is advised to employ the services of a competent patent draftsman outside the Office, as the U.S. Patent and Trademark Office no longer prepares new drawings. The corrected drawings are required in reply to the Office action to avoid abandonment of the application. The requirement for corrected drawings will not be held in abeyance.

***Claim Objections***

Claims 1-18 are objected to because of the following informalities:

Independent Claim 1 lines 3 etc. recites "associated with", it is not clear what Applicants' intend to exclude/include by the recitation "associated with". Further knowledge of one of ordinary skill in the art or specification, prior art do not clarify what Applicants' intend to exclude/ include by the expression.

Appropriate correction is required.

***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

A. Claims 1-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Saito et al. ( U.S. Patent No. 6,121,634, herein after Saito) previously applied and further in view of Appeldorn et al. ( U.S. Patent No. 4,146, 883 herein after Appeldorn).

With respect to claim 1 Saito describes nitride semiconductor light emitting device comprising at least a substrate, ( Saito fig. 6A # 200 , col. 8 line 19) an active layer formed of a nitride semiconductor containing mainly In and Ga, ( Saito fig. 6A #205, col. 8 line 24-25) an optical cavity,(inherently present in every LED) a p-electrode associated with the cavity , ( Saito fig. 6A #21 1 , col. 8 lines 32-33) and an n-electrode associated with said cavity , ( Saito figure 6A # 210, col.8 line 32 ) .

Saito does not specifically mention the presently newly added limitation namely wherein said p-electrode and/or said n-electrode is electrically separated into at least two regions.

However, Appeldorn, a patent from the same filed of endeavor, describes in figures 6-7 etc. and lines col. 5 lines 29-32, wherein said p-electrode and/or said n-electrode is electrically separated into at least two regions to provide a Led with uniform

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illumination using a thin structure that does not require the use of complicating and expansive elements such as masks or shields or light scattering media had a relatively cheaper chip by decreasing the size and/or the number of chips.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to include Appeldorn's p-electrode and/or said n-electrode is electrically separated into at least two regions in Saito's device . the motivation for the above combination is to provide a LED with uniform illumination using a thin structure that does not require the use of complicating and expansive elements such as masks or shields or light scattering media and a relatively cheaper chip by decreasing the size and/or the number of chips. ( Appeldorn col. 2 lines 52 to 60).

With respect to claim 2 Saito describes the nitride semiconductor light emitting diode according to claim 1, wherein said nitride semiconductor light emitting device has self pulsation characteristics. (Saito Abstract lines 4-6, etc. ).

With respect to claim 3 Saito describes a nitride semiconductor light emitting device according to claim 1 wherein said active layer has a band gap of at least 2-6 eV ( Saito col. 7 line 8-operation voltage 3.8 V) and said nitride semiconductor light emitting device has self pulsation characteristics. ( Saito Abstract lines 4-6).

With respect to claim 4 Siato describes the nitride semiconductor light emitting device according to claim 1, wherein said active layer has a band gap of at least 2.6 eV, ( Saito col. 7 line 8-operation voltage 3.8 V ) and said nitride semiconductor light emitting

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device has self pulsation characteristics in a light output range of at least 5 mW. (Saito col. 7 lines 14-16, up to 200mv).

**B.** Claims 5-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Saito et al. (U.S. Patent No. 6,121,634, herein after Saito) in view of Appeldorn et al. (U.S. Patent No. 4,146, 883 herein after Appeldorn), as applied to claims 1-4 above and further in view of Yoshida et al. (U.S. Patent No. 5,663,975, herein after Yoshida).

With respect to claim 5 Saito and Appeldorn describes the nitride semiconductor light emitting diode according to claim 1.

Saito and Appeldorn do not specifically describe the p-electrode and n-electrode are electrically short-circuited in at least one of the regions of said separated electrode.

However, Yoshida, patent from the same filed of endeavor, describes in figure 9 and col. 1 lines 19-25 describes the p-electrode (drive region first laser resonator) and n-electrode (drive region fourth laser resonator or vice versa) are electrically short-circuited in at least one of the regions of said separated electrode, to provide a common drive region and a total of operating currents supplied to the respective drive regions and the common drive region is made constant, whereby a temperature of the laser chip can be retained always substantially constant.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to include Yoshida's element of the p-electrode (drive region first laser resonator) and n-electrode (drive region fourth laser resonator or vice versa) are electrically short-circuited in at least one of the regions of said separated electrode in

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Saito's device . The motivation to make the above mentioned inclusion is to provide a common drive region and a total of operating currents supplied to the respective drive regions and the common drive region is made constant, whereby a temperature of the laser chip can be retained always substantially constant. (Yoshida col. 1 1 lines 19-32). With respect to claim 6 Saito describes the nitride semiconductor light emitting device according to claim 1 , wherein at least one of said p-electrode and said n-electrode is electrically separated into at least two regions, Yoshida fig.9 , regions 318 a to d) and the p-electrode and n-electrode are electrically short-circuited in at least one of the regions of said separated electrode, ( Yoshida figure 9 and col. 1 1 lines 19-25 ) and said nitride semiconductor light emitting device has self pulsation characteristics. (Saito Abstract lines 4-6) .

With respect to claim 7 Saito describes the nitride semiconductor light emitting device according to claim 1 , wherein said active layer has a bandgap of at least 2.6 eV, (Saito col. 7 line 8 operation voltage 3.8 V) and at least one of said p-electrode and said n-electrode is electrically separated into at least two regions ( Yoshida fig.9 , regions 318 a to d) and the p-electrode and n-electrode are electrically short-circuited in at least one of the regions of said separated electrode, (Yoshida col. 1 1 lines 19-25) and said nitride semiconductor light emitting device has self pulsation characteristics. ( Saito Abstract lines 4-6).

With respect to claim 8, Saito describes the nitride semiconductor light emitting device according to claim 1 , wherein said active layer has a bandgap of at least 2.6 eV,

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(Saito col. 7 line 8 operation voltage 3.8 V) and at least one of said p-electrode and said n-electrode is separated electricity into at least two regions, (Yoshida fig.9, regions 318 a to d) and the p-electrode and n-electrode are electrically short-circuited in at least one of the regions of said separated electrode, and said nitride semiconductor light emitting device has self pulsation characteristics in a light output range of at least 5 mW. (Saito col. 7 lines 14-16).

With respect to claim 9, Saito describes the nitride semiconductor light emitting device according to claim 1, wherein one of said electrodes electrically separated into at least two regions forms contact with one of two mirror facets forming a cavity, (Yoshida figures 9, 16-22, col. 12 lines 3 to 6, col. 18 lines 7-10) and said mirror facet has a reflection film containing a conductive material, (Yoshida figures 9, 16-22, col. 12 lines 3 to 6, col. 18 lines 10-16) and the p-electrode and n-electrode are electrically connected by said reflection film. (Yoshida figure 9, col. 12 lines 7-15).

With respect to claim 10 Saito describes the nitride semiconductor light emitting device according to claim 9, wherein one of said electrodes electrically separated into at least two regions forms contact with one of two mirror facets forming a cavity at a side opposite to an output plane. (Yoshida figures, 16, etc.).

With respect to claim 11, Saito describes the nitride semiconductor light emitting device according to claim 9, wherein said conductive material includes Al. (Yoshida col. 11 line 57).

With respect to claim 12, Saito describes the nitride semiconductor light emitting



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device according to claim 1 , wherein a resistor is provided between said p-electrode and said n-electrode in at least one of the regions of said electrode electrically separated into at least two regions. ( Yoshida claim 14).

With respect to claim 13, Saito describes the nitride semiconductor light emitting device according to claim 2, wherein self pulsation characteristics are adjusted by said resistor provided between said p-electrode and said n-electrode. ( Yoshida claim 14)

With respect to claims 14 and 15 , Saito describes the nitride semiconductor light emitting device according to claim 1, wherein Si is added as n type impurities into said active layer, and a concentration of said Si is  $1 \times 10^{17}/\text{cm}^3$  to  $5 \times 10^{18}/\text{cm}^3$ . ( Saito col. 6 lines 45-50, conc. Figure 2- Si as ntype impurities inherent).

With respect to claim 16, Saito describes the nitride semiconductor light emitting device according to claim 1 , wherein at least one of said p-electrode and said n-electrode is electrically separated into at least two regions, and the p-electrode and n-electrode are electrically short-circuited in at least one of the regions of said separated electrode, and a range of  $0.02 \leq L1/E2 \leq 0.30$  is established, where L1 is a total length of the region where the p-electrode and n-electrode are electrically short-circuited, and L.2 is a total length of the region not short-circuited, among the electrode separate', into regions. ( Yoshida figures 9, 16 , etc. and col. 18 lines 9-10).

With respect to claims 17 and 18, Saito describes the nitride semiconductor light emitting device according to claim 1, wherein connection is established such that at least one of said electrodes separated into at least two regions has reverse bias applied

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to said active layer and another of said electrodes separated into at least two regions has forward bias applied to the active layer. ( Yoshida description of figures 9, 16 'etc-).

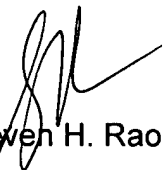
***Response to Arguments***

Applicant's arguments with respect to claims 1-18 have been considered but are moot in view of the new ground(s) of rejection.

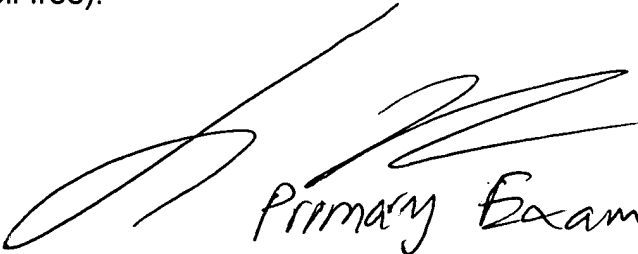
Any inquiry concerning this communication or earlier communications from the examiner should be directed to Steven H. Rao whose telephone number is ( 571) 272-1718. The examiner can normally be reached on 8.00 to 5.00.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

  
Steven H. Rao  
Patent Examiner

April 12, 2005.

  
Primary Examiner  
LONG PHAN